

**EAST Search History****EAST Search History (Prior Art)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	10/584133	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 19:26
L2	2	("6156479").PN.	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/08 19:27
L3	2	("5919599").PN.	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/08 19:27
L4	2	("5919598").PN.	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/08 19:27
L5	0	(metal adj nitride adj particles) and (organic adj solvent) and (organic adj material)	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 19:28
L6	10	(metal adj nitride adj particles) and (organic adj solvent) and (organic adj material)	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 19:29

L7	10	6 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or minutes or coating or photo or heating or beaking or annealing or light or exposed or wavelength or "157" or "248" or "193")	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 19:33
L8	2	("20050076581").PN.	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/08 19:54
L9	2	("7427361").PN.	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/08 19:55
L10	2	("7094514").PN.	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/08 19:55
L11	2	("6117775").PN.	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/08 19:55

L12	2	2 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or minutes or coating or photo or heating or beaking or annealing or light or exposed or wavelength or "157" or "248" or "193")	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 19:56
L13	2	3 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or minutes or coating or photo or heating or beaking or annealing or light or exposed or wavelength or "157" or "248" or "193")	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 19:58
L14	2	4 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or minutes or coating or photo or heating or beaking or annealing or	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:02

		light or exposed or wavelength or "157" or "248" or "193")				
L15	:2	10 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or minutes or coating or photo or heating or beaking or annealing or light or exposed or wavelength or "157" or "248" or "193")	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:04
L16	:2	11 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or minutes or coating or photo or heating or beaking or annealing or light or exposed or wavelength or "157" or "248" or "193")	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:12
L17	:2	9 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:14

			minutes or coating or photo or heating or beaking or annealing or light or exposed or wavelength or "157" or "248" or "193")				
L18	2396	438/680	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:32	
L19	4053	438/706	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33	
L20	1478	438/712	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33	
L21	0	438/7724	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33	
L22	1307	438/724	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33	
L23	2087	438/725	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33	
L24	2792	438/758	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33	

L25	561	438/744	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33
L26	555	438/757	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33
L27	1021	438/782	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 20:33
L28	18	(metal adj nitride adj particles) and (organic adj solvent) and wavelength	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 21:05
L29	18	28 and (1 or "1000" or nm or semiconductor or device or solvent or organic or material or composition or nitride or particle or particles or titanium or tungsten or tantalum or oxynitride or cesium or gallium or germanium or hafnium or polymer or temperature or "80" or "300" or "10" or "0.5" or minutes or coating or photo or heating or beaking or annealing or light or exposed or wavelength or "157" or "248" or "193")	US_PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/08 21:07

8/8/2009 9:43:54 PM